



US 20110021654A1

(19) **United States**

(12) **Patent Application Publication**
Matano et al.

(10) **Pub. No.: US 2011/0021654 A1**

(43) **Pub. Date: Jan. 27, 2011**

(54) **NOVEL CATIONIC
PHOTOPOLYMERIZATION INITIATOR**

(75) Inventors: **Yoshihiro Matano**, Kyoto (JP);
Hiroshi Imahori, Kyoto (JP)

Correspondence Address:
KRATZ, QUINTOS & HANSON, LLP
1420 K Street, N.W., 4th Floor
WASHINGTON, DC 20005 (US)

(73) Assignee: **KYOTO UNIVERSITY**, Kyoto-shi
(JP)

(21) Appl. No.: **12/922,278**

(22) PCT Filed: **Dec. 11, 2008**

(86) PCT No.: **PCT/JP2008/072545**

§ 371 (c)(1),
(2), (4) Date: **Sep. 13, 2010**

(30) **Foreign Application Priority Data**

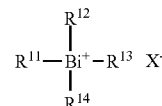
Mar. 11, 2008 (JP) 2008-061205

Publication Classification

(51) **Int. Cl.**
C08F 2/46 (2006.01)
C07F 9/94 (2006.01)
(52) **U.S. Cl.** **522/31; 556/30; 556/7; 556/13**

(57) **ABSTRACT**

An object of the present invention is to provide a novel cationic photopolymerization initiator that efficiently absorbs light and generates protons. As a means of achieving the object above, a preferred cationic photopolymerization initiator of the present invention includes an initiator comprising a bismuthonium salt represented by the following general formula (II):



Wherein

R¹¹, R¹², and R¹³ may be the same or different and are each an optionally substituted monocyclic aryl group or an optionally substituted monocyclic heteroaryl group, R¹⁴ is an optionally substituted fused polycyclic aromatic group or an optionally substituted fused polycyclic heterocyclic group, and X⁻ is an anion associated with a cation.

NOVEL CATIONIC PHOTOPOLYMERIZATION INITIATOR

TECHNICAL FIELD

[0001] The present invention relates to a novel cationic photopolymerization initiator that efficiently absorbs light and generates protons.

BACKGROUND ART

[0002] As is widely known, in recent years, as photo-curable resin compositions for use in printing ink, paint, a coating material, and the like, those utilizing a cationic photopolymerization reaction have attracted attention as well as those utilizing a radical photopolymerization reaction. A photo-curable resin composition utilizing a cationic photopolymerization reaction contains, as main components, a cationic photopolymerizable compound, which contains, for example, an epoxy group, an oxetane group, a vinyl ether group, etc., and a cationic photopolymerization initiator for the polymerization of such a compound. The cationic photopolymerization initiator plays a role in generating protons to initiate a cationic photopolymerization reaction. Well known examples thereof include sulfonium salt based cationic photopolymerization initiators and iodonium salt based cationic photopolymerization initiators.

[0003] A cationic photopolymerization initiator is required to have such characteristics that, for example, it efficiently absorbs light, the bond between the cation atom and the carbon atom of the substituent (e.g., S⁺-Ph bond or I⁺-Ph bond) is easily cleaved, and the cation atom is susceptible to reduction. Some of the already commercially available cationic photopolymerization initiators are excellent in these characteristics, but there is a demand for a cationic photopolymerization initiator with further improved characteristics.

DISCLOSURE OF THE INVENTION

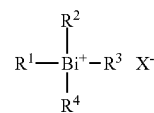
Problems that the Invention is to Solve

[0004] An object of the present invention is to provide a novel cationic photopolymerization initiator that efficiently absorbs light and generates protons.

Means for Solving the Problems

[0005] In the course of study in view of the above problems, the present inventors focused attention on bismuth in Group 15, Period 6. The binding energy of bismuth to carbon is small compared with other light elements in the same group, and pentavalent bismuth is easily reduced to trivalent bismuth. Further, the toxicity of bismuth is much lower than heavy elements therearound. The present inventors thus conducted extensive research on the use of bismuth as a cationic photopolymerization initiator. As a result, they found that an onium salt of bismuth (bismuthonium salt) functions effectively as a cationic photopolymerization initiator.

[0006] A cationic photopolymerization initiator of the present invention accomplished based on the above findings is, as described in claim 1, characterized by comprising a bismuthonium salt represented by the following general formula (1):



wherein

[0007] R¹ and R² may be the same or different and are each an optionally substituted monocyclic aryl group or an optionally substituted monocyclic heteroaryl group,

[0008] R³ and R⁴ may be the same or different and are each an optionally substituted monocyclic aryl group; an optionally substituted monocyclic heteroaryl group; an optionally substituted fused polycyclic aromatic group; an optionally substituted fused polycyclic heterocyclic group; —CH=CR⁵R⁶, wherein R⁵ and R⁶ may be the same or different and are each a hydrogen atom, an optionally substituted alkyl group, an optionally substituted monocyclic aryl group, an optionally substituted monocyclic heteroaryl group, an optionally substituted fused polycyclic aromatic group, or an optionally substituted fused polycyclic heterocyclic group; or —(CH₂)_n—COR⁷, wherein R⁷ is an optionally substituted alkyl group, an optionally substituted monocyclic aryl group, an optionally substituted monocyclic heteroaryl group, an optionally substituted fused polycyclic aromatic group, or an optionally substituted fused polycyclic heterocyclic group, and n is 1 or 2, and

[0009] X⁻ is an anion associated with a cation.

[0010] A cationic photopolymerization initiator according to claim 2 is characterized in that in the cationic photopolymerization initiator according to claim 1, R¹, R², and R³ are each an optionally substituted monocyclic aryl group.

[0011] A cationic photopolymerization initiator according to claim 3 is characterized in that in the cationic photopolymerization initiator according to claim 1, at least one of R³ and R⁴ is an optionally substituted fused polycyclic aromatic group.

[0012] A cationic photopolymerization initiator according to claim 4 is characterized in that in the cationic photopolymerization initiator according to claim 1, X⁻ is PF₆⁻, SbF₆⁻, AsF₆⁻, BF₄⁻, ORf⁻, NRf₂⁻, or B (Ar)₄⁻, wherein Rf is a perfluoroalkylsulfonyl group and Ar is an optionally substituted aryl group.

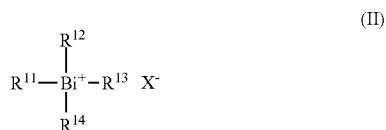
[0013] A method for polymerizing a cationic photopolymerizable compound of the present invention is, as described in claim 5, characterized by using a cationic photopolymerization initiator according to claim 1.

[0014] A method according to claim 6 is characterized in that in the method according to claim 5, the cationic photopolymerizable compound is a compound containing at least one member selected from an epoxy group, an oxetane group, and a vinyl ether group.

[0015] A photo-curable resin composition of the present invention is, as described in claim 7, characterized by at least comprising a cationic photopolymerizable compound and a cationic photopolymerization initiator according to claim 1.

[0016] A cured product of the present invention is, as described in claim 8, characterized by being obtainable by curing a photo-curable resin composition according to claim 7.

[0017] A bismuthonium salt of the present invention is, as described in claim 9, characterized by being represented by the following general formula (II):



wherein

[0018] R¹¹, R¹², and R¹³ may be the same or different and are each an optionally substituted monocyclic aryl group or an optionally substituted monocyclic heteroaryl group,

[0019] R¹⁴ is an optionally substituted fused polycyclic aromatic group or an optionally substituted fused polycyclic heterocyclic group, and

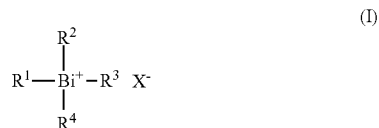
[0020] X⁻ is an anion associated with a cation.

EFFECT OF THE INVENTION

[0021] The present invention allows the provision of a novel cationic photopolymerization initiator that efficiently absorbs light and generates protons.

BEST MODE FOR CARRYING OUT THE INVENTION

[0022] The cationic photopolymerization initiator of the present invention is characterized by comprising a bismuthonium salt represented by the following general formula (I):



wherein

[0023] R¹ and R² may be the same or different and are each an optionally substituted monocyclic aryl group or an optionally substituted monocyclic heteroaryl group,

[0024] R³ and R⁴ may be the same or different and are each an optionally substituted monocyclic aryl group; an optionally substituted monocyclic heteroaryl group; an optionally substituted fused polycyclic aromatic group; an optionally substituted fused polycyclic heterocyclic group; —CH=CR⁵R⁶, wherein R⁵ and R⁶ may be the same or different and are each a hydrogen atom, an optionally substituted alkyl group, an optionally substituted monocyclic aryl group, an optionally substituted monocyclic heteroaryl group, an optionally substituted fused polycyclic aromatic group, or an optionally substituted fused polycyclic heterocyclic group; or —(CH₂)_n—COR⁷, wherein R⁷ is an optionally substituted alkyl group, an optionally substituted monocyclic aryl group, an optionally substituted monocyclic heteroaryl group, an optionally substituted fused polycyclic aromatic group, or an optionally substituted fused polycyclic heterocyclic group, and n is 1 or 2, and

[0025] X⁻ is an anion associated with a cation.

[0026] An example of the monocyclic aryl group of the optionally substituted monocyclic aryl group for R¹, R², R³, R⁴, R⁵, R⁶, and R⁷ is a phenyl group.

[0027] Examples of the monocyclic heteroaryl group of the optionally substituted monocyclic heteroaryl group for R¹, R², R³, R⁴, R⁵, R⁶, and R⁷ include a thienyl group, a pyrrolyl group, a pyridyl group, and a furyl group.

[0028] Examples of the fused polycyclic aromatic group of the optionally substituted fused polycyclic aromatic group for R³, R⁴, R⁵, R⁶, and R⁷ include a naphthyl group, a phenanthryl group, a pyrenyl group, a tetracenyl group, a pentacenyl group, a triphenylenyl group, and a perylenyl group.

[0029] Examples of the fused polycyclic heterocyclic group of the optionally substituted fused polycyclic heterocyclic group for R³, R⁴, R⁵, R⁶, and R⁷ include a carbazoyl group, a phenanthrolyl group, and an acridinyl group.

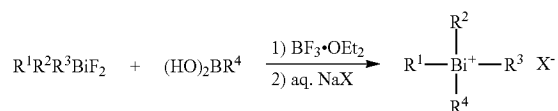
[0030] Examples of the alkyl group of the optionally substituted alkyl group for R⁵, R⁶, and R⁷ include C₁₋₁₈ alkyl groups such as a methyl group, an ethyl group, a propyl group, an isopropyl group, a butyl group, an isobutyl group, a sec-butyl group, a tert-butyl group, a pentyl group, an isopentyl group, a hexyl group, a cyclohexyl group, an octyl group, a decyl group, dodecyl, hexadecyl, and octadecyl.

[0031] Examples of substituents of the optionally substituted monocyclic aryl group, the optionally substituted monocyclic heteroaryl group, the optionally substituted fused polycyclic aromatic group, and the optionally substituted fused polycyclic heterocyclic group include C₁₋₁₈ alkyl groups (optionally substituted) such as a methyl group, an ethyl group, a propyl group, an isopropyl group, a butyl group, an isobutyl group, a sec-butyl group, a tert-butyl group, a pentyl group, an isopentyl group, a hexyl group, a cyclohexyl group, an octyl group, a decyl group, dodecyl, hexadecyl, and octadecyl; C₂₋₁₀ alkenyl groups (optionally substituted) such as a vinyl group, an allyl group, a butenyl group, a 2-methyl-1-propenyl group, a 2-methyl-2-propenyl group, and a 1-methyl-1-propenyl group; C₁₋₁₀ alkoxy groups (optionally substituted) such as a methoxy group, an ethoxy group, a propoxy group, a butoxy group, a tert-butoxy group, a pentyloxy group, and a hexyloxy group; aryl groups (optionally substituted) such as a phenyl group and a naphthyl group; heteroaryl groups (optionally substituted) such as a thienyl group, a pyrrolyl group, a pyridyl group, and a furyl group; arylthio groups (optionally substituted) such as a phenylthio group; arylalkyl groups (optionally substituted) such as a benzyl group, a phenylethyl group, a 3-phenylpropyl group, a 1-naphthylmethyl group, a 2-naphthylmethyl group, a 2-(1-naphthyl)ethyl group, a 2-(2-naphthyl)ethyl group, a 3-(1-naphthyl)propyl group, and a 3-(2-naphthyl)propyl group; heteroarylalkyl groups (optionally substituted) such as a 2-pyrrolylmethyl group, a 2-pyridylmethyl group, a 3-pyridylmethyl group, a 4-pyridylmethyl group, a 2-thienylmethyl group, a 2-(2-pyridyl)ethyl group, a 2-(3-pyridyl)ethyl group, a 2-(4-pyridyl)ethyl group, and a 3-(2-pyrrolyl)propyl group; dialkylamino groups such as a dimethylamino group and a diethylamino group; halogen atoms such as fluorine, chlorine, bromine, and iodine; a cyano group; and a nitro group. Examples of substituents of the optionally substituted alkyl group are the above-mentioned alkenyl groups, alkoxy groups, aryl groups, heteroaryl groups, arylthio groups, dialkylamino groups, halogen atoms, a cyano group, a nitro group, etc.

[0032] X⁻ may be, for example, PF₆⁻, SbF₆⁻, AsF₆⁻, BF₄⁻, ORf⁻, NRf₂⁻, or B(Ar)₄⁻ (Rf is a perfluoroalkylsulfonyl group, and Ar is an optionally substituted aryl group) (an example of the perfluoroalkylsulfonyl group is one having a C₁₋₈ perfluoroalkyl moiety, such as a trifluoromethanesulfo-

nyl group, and the optionally substituted aryl group is as defined above). SbF_6^- allows protons to be generated effectively and thus is preferable.

[0033] The bismuthonium salt represented by the above general formula (I) may be a known compound based on the research results that have been achieved by the present inventors (see, e.g., *Organometallics* 1998, 17, 4332-4334). Even in the case where the bismuthonium salt is an unknown compound, it can be synthesized according to the above reference by the following reaction:



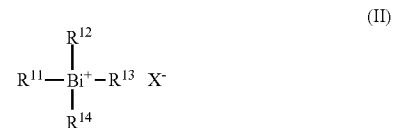
wherein

[0034] R^1 , R^2 , R^3 , R^4 , and X^- are as defined above, and

[0035] NaX is a sodium salt corresponding to X^- .

[0036] The cationic photopolymerization initiator of the present invention is suitable for the polymerization of a cationic photopolymerizable compound containing an epoxy group, an oxetane group, a vinyl ether group, etc., for example. The cationic photopolymerization initiator of the present invention is mixed with a cationic photopolymerizable compound to produce a photo-curable resin composition, and the composition is applied to a substrate (e.g., a substrate made of a metal or a synthetic resin; however, the material of the substrate is not limited thereto), for example, and then irradiated with light having a wavelength within a range of 300 to 500 nm for 10 seconds to 3 hours, for example. As a result, protons are effectively generated, and a cationic photopolymerization reaction takes place in the cationic photopolymerizable compound, resulting in a cured product. The amount of the cationic photopolymerization initiator of the present invention present in the photo-curable resin composition is 0.01 to 5 mol %, for example, relative to the cationic photopolymerizable compound. The photo-curable resin composition may contain perylene, acridine orange, acridine yellow, benzoflavin, setoflavin T, pyrene, 9,10-dibutoxyanthracene, 1,2-benzanthracene, phenothiazin, coronene, thioxanthone, fluorenone, benzophenone, anthraquinone, or the like as a sensitizer for promoting the cationic photopolymerization reaction. In such a case, the amount of the sensitizer (preferably having a molar extinction coefficient of, for example, $3000 \text{ M}^{-1} \text{ cm}^{-1}$ or more, and more preferably $5000 \text{ M}^{-1} \text{ cm}^{-1}$ or more) to be added may be about $1/100$ to $1/5$ relative to the cationic photopolymerization initiator of the present invention (molar ratio). Light to be applied may be suitably selected within a wavelength range of 300 to 700 nm, for example, according to the light absorption characteristics of the sensitizer. The light source may be a high pressure mercury lamp. Alternatively, any of various lasers, a xenon lamp, a halogen lamp, or the like is also usable.

[0037] In the present invention, a preferred example of the cationic photopolymerization initiator is an initiator comprising a bismuthonium salt represented by the following general formula (II):



wherein

[0038] R^{11} , R^{12} , and R^{13} may be the same or different and are each an optionally substituted monocyclic aryl group or an optionally substituted monocyclic heteroaryl group,

[0039] R^{14} is an optionally substituted fused polycyclic aromatic group or an optionally substituted fused polycyclic heterocyclic group, and

[0040] X^- is an anion associated with a cation.

[0041] The bismuthonium salt represented by the above general formula (II) has a fused polycyclic aromatic group or a fused polycyclic heterocyclic group bonded to the Bi cation atom, and thus is capable of efficiently absorbing light having a longer wavelength ($h\nu > 350 \text{ nm}$) and generating protons. Accordingly, such a bismuthonium salt is suitable for use on the industrial scale, and can also be synthesized easily by the method of the above-mentioned reference.

EXAMPLES

[0042] Hereinafter, the present invention will be described in detail with reference to the examples, but the scope of the present invention is not limited to the following descriptions.

Example 1

(A) Synthesis of Bismuthonium Salt

(1) Synthesis of tris(4-methylphenyl)(1-pyrenyl) bismuthonium Salt with SbF_6^- as Anion ($2a.\text{SbF}_6$)

[0043] $\text{BF}_3\cdot\text{OEt}_2$ (0.23 mL, 2.0 mmol) was added dropwise at 0°C . to a methylene chloride solution (10 mL) containing tris(4-methylphenyl)bismuth difluoride (0.52 g, 1 mmol) and 1-pyrenylboric acid (0.27 g, 1.1 mmol), and the mixture was stirred at room temperature for 2 hours. An aqueous solution of NaSbF_6 (5.2 g, 20 mmol) was added thereto, then the resulting two-layer liquid was vigorously stirred for 20 minutes, and the aqueous layer was separated and extracted with methylene chloride. The methylene chloride solution was collected, dried over magnesium sulfate, and passed through a short silica gel column. The eluate was concentrated under reduced pressure, and the resulting solid was recrystallized from methylene chloride—diethyl ether to give the target compound as a pale yellow crystal (yield: 95%, 0.87 g).

[0044] Mp $180\text{--}182^\circ \text{C}$.; $^1\text{H NMR}$ (CDCl_3) δ 2.47 (s, 9H), 7.54 (d, 6H, $J=7.6 \text{ Hz}$), 7.68 (d, 6H, $J=7.6 \text{ Hz}$), 7.84 (d, 1H, $J=8.8 \text{ Hz}$), 8.17 (t, 1H, $J=7.8 \text{ Hz}$), 8.19 (d, 1H, $J=8.8 \text{ Hz}$), 8.22 (d, 1H, $J=8.8 \text{ Hz}$), 8.29 (d, 2H, $J=8.8 \text{ Hz}$), 8.32 (d, 1H, $J=7.8 \text{ Hz}$), 8.35–8.43 (m, 2H); $^{13}\text{C}\{^1\text{H}\}$ NMR (CDCl_3) δ 21.6, 123.9, 125.5, 126.9, 127.1, 127.2, 127.4, 127.6, 128.1, 128.9, 130.2, 130.4, 130.9, 131.4, 131.6, 133.2, 133.5, 134.5, 135.3, 143.9; IR (KBr) ν_{max} 1584, 1488, 1456, 1392, 1312, 1239, 1207, 1189, 1053, 1004, 849, 795, 709, 656 (SbF_6^-), 474 cm^{-1} ; UV-Vis (CH_2Cl_2) λ_{max} (ϵ) 342 (27000), 352 (31000), 358 (30000), 377 nm ($9600 \text{ M}^{-1} \text{ cm}^{-1}$); MS (MALDI-TOF)

m/z 683 ($[M-SbF_6]^+$). Anal. Calcd for $C_{37}H_{30}BiF_6Sb$: C, 48.34; H, 3.29. Found: C, 48.19; H, 3.26.

(2) Synthesis of
tris(4-methylphenyl)(1-pyrenyl)bismuthonium Salt
with PF_6^- as Anion (2a. PF_6)

[0045] The compound was synthesized in the same manner as above.

[0046] Mp 179-182° C. (decomp); 1H NMR ($CDCl_3$) δ 2.46 (s, 9H), 7.54 (d, 6H, $J=7.6$ Hz), 7.68 (d, 6H, $J=7.6$ Hz), 7.83 (d, 1H, $J=8.8$ Hz), 8.15 (t, 1H, $J=7.6$ Hz), 8.17 (d, 1H, $J=8.4$ Hz), 8.22 (d, 1H, $J=8.8$ Hz), 8.27 (d, 2H, $J=8.8$ Hz), 8.31 (d, 1H, $J=7.6$ Hz), 8.37 (d, 1H, $J=7.6$ Hz), 8.40 (d, 1H, $J=8.4$ Hz); IR (KBr) ν_{max} 1584, 1487, 1454, 1392, 1311, 1239, 1208, 1189, 1053, 1005, 900-700 (PF_6^-), 707 cm^{-1} ; UV-Vis (CH_2Cl_2) λ_{max} (ϵ) 342 (25000), 352 (29000), 358 (28000), 377 nm ($8900 M^{-1} cm^{-1}$); MS (MALDI-TOF) m/z 683 (M^+-PF_6). Anal. Calcd for $C_{37}H_{30}BiF_6P$: C, 53.63; H, 3.65. Found: C, 53.63; H, 3.52.

(3) Synthesis of
tris(4-methylphenyl)(1-pyrenyl)bismuthonium Salt
with BF_4^- as Anion (2a. BF_4)

[0047] The compound was synthesized in the same manner as above.

[0048] Mp 231-233° C.; 1H NMR ($CDCl_3$) δ 2.45 (s, 9H), 7.50 (d, 6H, $J=8.1$ Hz), 7.74 (d, 6H, $J=8.1$ Hz), 7.82 (d, 1H, $J=8.8$ Hz), 8.14 (t, 1H, $J=7.6$ Hz), 8.16 (d, 1H, $J=9.2$ Hz), 8.17 (d, 1H, $J=9.2$ Hz), 8.26 (d, 1H, $J=8.8$ Hz), 8.29 (d, 1H, $J=7.3$ Hz), 8.32 (d, 1H, $J=8.1$ Hz), 8.36 (d, 1H, $J=7.3$ Hz), 8.38 (d, 1H, $J=8.1$ Hz); IR (KBr) ν_{max} 1584, 1486, 1463, 1391, 1312, 1241, 1206, 1150-900 (BF_4^-), 848, 796, 705 cm^{-1} ; UV-Vis (CH_2Cl_2) λ_{max} (ϵ) 341 (26000), 352 (29000), 358 (27000), 377 nm ($8800 M^{-1} cm^{-1}$); MS (FAB) m/z 683 (M^+-BF_4). Anal. Calcd for $C_{37}H_{30}BBiF_4$: C, 57.68; H, 3.92. Found: C, 57.62; H, 3.88.

(4) Synthesis of triphenyl(1-pyrenyl)bismuthonium
Salt with SbF_6^- as Anion (2b. SbF_6)

[0049] The compound was synthesized in the same manner as above.

[0050] Mp 176-177° C.; 1H NMR ($CDCl_3$, 400 MHz) δ 7.68-7.77 (m, 9H), 7.83 (br-s, 6H), 7.85 (d, 1H, $J=8.8$ Hz), 8.16-8.24 (m, 3H), 8.29-8.34 (m, 3H), 8.39-8.43 (m, 2H); IR (KBr) ν_{max} 1584, 1566, 1475, 1437, 991, 850, 816, 730, 709, 685, 659 (SbF_6^-) cm^{-1} ; UV-Vis ($CHCl_3$) λ_{max} (ϵ) 351 (29900), 377 nm ($6900 M^{-1} cm^{-1}$); MS (MALDI-TOF) m/z 642 ($[M-SbF_6]^+$). Anal. Calcd for $C_{34}H_{24}BiF_6Sb$: C, 46.55; H, 2.76. Found: C, 46.33; H, 2.74.

(B) Photolysis of Bismuthonium Salt

[0051] An acetonitrile solution of a bismuthonium salt 2.X (2a. SbF_6 , 2a. PF_6 , 2a. BF_4 , and 2b. SbF_6) (0.010 M, 1.5 mL) was placed into a Pyrex® tube, and optionally an excessive amount of hexamethylphosphoric triamide or 2,6-di-tert-butyl-4-methylpyridine was added thereto. Subsequently, through a septum, argon was passed through the solution for 5 minutes. The obtained solution was then irradiated with light using a 250 W ultra high pressure mercury lamp (USHIO SX-UI250HP) as a light source through an aqueous copper sulfate solution filter (5.0 wt %, 5 cm). The bismuthonium salt 2.X was completely consumed in 2 minutes. The resulting reaction mixture was concentrated under reduced

pressure, and the residue was dissolved in 0.5 mL of deuterated chloroform containing 1,1,2,2-tetrachloroethane (3.2 μ L; internal standard). The product was identified by 1H -NMR, and the yield was also determined thereby. The quantum yield of the photolytic reaction was determined by a comparison with a potassium ferrioxalate actinometer (in order to avoid a side reaction of the product, the quantum yield was determined at the time when about 10% of the bismuthonium salt 2.X was consumed). The results are shown in Table 1.

TABLE 1

Photochemical reaction of 2 · X in acetonitrile. ^{a,b}					
entry	2 · X	Φ_{dec}	additive	products (NMR yield/% ^c)	
1	2a · BF_4	N.d. ^d	none	3a (30), pyrene (70) ^e	
2	2a · BF_4	N.d. ^d	HMPA	3a (25), 4a · BF_4 (65), pyrene (75)	
3	2a · BF_4	0.20	py ^f	3a (70), pyrene (nd), $pyH^+BF_4^-$ (90) ^f	
4	2a · PF_6	0.22	HMPA	3a (20), 4a · PF_6 (65), pyrene (80)	
5	2a · SbF_6	0.22	HMPA	3a (25), 4a · SbF_6 (70), pyrene (80)	
6	2b · SbF_6	0.22	HMPA	3b (20), 4b · SbF_6 (70), pyrene (80)	

^aThe photoirradiation was carried out with a high pressure Hg arc lamp through an aqueous $CuSO_4$ filter at room temperature.

^ba: Ar = p-MeC₆H₄; b: Ar = Ph.

^cDetermined by 1H NMR using an internal standard (1,1,2,2-tetrachloroethane).

^dNot determined.

^eInsoluble substances were formed.

^fpy = 2,6-di-tert-butyl-4-methylpyridine.

[0052] As is obvious from Table 1, as a result of the photolysis of the bismuthonium salt 2.X, tris(4-methylphenyl)bismuthine or triphenylbismuthine and pyrene were obtained as main products. These results were attributed to preferential homolysis of the bond between the ipso-carbon atom of the pyrenyl group and the Bi cation atom due to irradiation with light. In the presence of an excessive amount of hexamethylphosphoric triamide or 2,6-di-tert-butyl-4-methylpyridine, the production of a salt thereof was observed. It was thus revealed that this reaction allows protons to be released into the system. These results confirm the function of a bismuthonium salt 2.X as a cationic photopolymerization initiator.

(C) Cationic Photopolymerization Reaction using
Bismuthonium Salt as Cationic Photopolymerization
Initiator

[0053] Using the same container and light irradiation apparatus as used in (B), the following procedure was followed. A

monomer (0.8 mL) and a bismuthonium salt 2.X were placed into a sample tube, and argon was passed therethrough for 5 minutes for substitution. This photo-curable resin composition was irradiated with light for a predetermined period of time, and then the reaction mixture was poured into methanol. The precipitate was filtered off and washed with methanol, and then dried under vacuum. The molecular weight of the obtained polymer was determined using a GPC column calibrated with polyethylene oxide standards. The results are shown in Table 2.

TABLE 2

Photoinduced cationic polymerization using 2 · X. ^a					
entry	initiator (mol %)	monomer	time	yield/% ^b	M _n (M _w /M _n) ^c
1	none	5	1 min	N.r. ^d	—(—)
2	2a · SbF ₆ (0.1)	5	1 h ^e	N.r. ^d	—(—)
3	2a · SbF ₆ (0.1)	5	1 min	88	9500 (1.2)
4	2a · PF ₆ (0.1)	5	1 min	41	8900 (1.3)
5	2a · PF ₆ (0.1)	5	3 min	46	9000 (1.3)
6	2a · PF ₆ (1)	5	1 min	58	8500 (1.4)
7	2a · BF ₄ (0.1)	5	1 min	<1	N.d. (N.d.) ^f
8	2a · BF ₄ (1)	5	3 min	<1	N.d. (N.d.) ^f
9	2b · SbF ₆ (0.1)	5	1 min	80	9000 (1.2)
10	3b (0.1)	5	1 min	N.r. ^d	—(—)
11	2a · SbF ₆ (0.1)	6	1 min ^g	48	7800 (1.2)
12	2a · SbF ₆ (0.5)	6	1 min ^g	59	8400 (1.2)
13	2a · SbF ₆ (0.1)	7	1 min	90	15800 (1.4)
14	2b · SbF ₆ (0.1)	7	1 min	85	16100 (1.4)
15	2a · SbF ₆ (0.1)	8	1 min	74	16600 (1.7)

^aThe photoirradiation was carried out with a high pressure Hg arc lamp through an aqueous CuSO₄ filter at room temperature.

^bIsolated yields of polymers.

^cM_n and M_w were determined by GPC (JAIGEL-5H—AF, eluted with CHCl₃) using poly(ethylene glycol) as a standard.

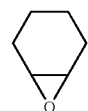
^dNo reaction.

^eNo irradiation.

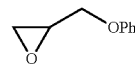
^fNot determined.

^gAfter irradiation, the reaction mixture was stood in the dark for 30 min.

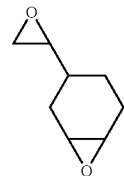
monomer:



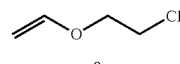
5



6



7



8

[0054] As is obvious from Table 2, when the bismuthonium salt 2.X was used as a cationic photopolymerization initiator,

it could be confirmed that a polymer was produced by a cationic photopolymerization reaction of the monomer.

Example 2

Comparison (I) Between Effects of Cationic Photopolymerization Initiator Comprising Bismuthonium Salt And of Existing Cationic Photopolymerization Initiator on Cationic Photopolymerization Reaction Using Sensitizer

[0055] This experiment was conducted in the same manner as in Example 1, (C), using cyclohexene oxide as a monomer and, as a bismuthonium salt, a tetrakis(4-methylphenyl)bismuthonium salt with SbF₆⁻ as an anion (synthesized from tris(4-methylphenyl)bismuth difluoride and 4-methylphenylboric acid in the same manner as in Example 1, (A)); the physicochemical properties thereof are as shown below) (0.1 mol % relative to the monomer). In this experiment, perylene in 1/10 the amount of the bismuthonium salt (molar ratio) was added as a sensitizer. The results are shown in Table 3. Table 3 also shows the results of an experiment conducted in the same manner using as an existing cationic photopolymerization initiator a tris(4-methylphenyl)sulfonium salt with SbF₆⁻ as an anion.

TABLE 3

Initiator	Time (min)	Yield/% ^a	M _n (M _w /M _n) ^b
Bismuthonium salt	0.5	38	8700 (1.2)
	1.0	86	7900 (1.2)
Sulfonium salt	0.5	22	7500 (1.2)
	1.0	78	6900 (1.2)

^{a,b}the same as in Table 2

[0056] As is obvious from Table 3, it was revealed that in a cationic photopolymerization reaction using a sensitizer, a cationic photopolymerization initiator comprising a bismuthonium salt is superior to an existing cationic photopolymerization initiator in terms of yield and degree of polymerization.

(Reference)

[0057] Physicochemical properties of tetrakis(4-methylphenyl)bismuthonium salt with SbF₆⁻ as anion Mp 175-178°C.; ¹H NMR δ 2.46 (s, 12H), 7.52 (d, 8H, J=8.0 Hz), 7.58 (d, 8H, J=8.0 Hz); ¹³C NMR δ 21.6, 131.4, 133.4, 135.4, 143.9; IR (KBr) ν_{max} 1581, 1488, 1447, 1392, 1312, 1208, 1188, 1120, 1054, 1004, 835, 794, 656 (SbF₆⁻), 473 cm⁻¹; MS (MALDI TOF) m/z 573 (M⁺-SbF₆). Anal. Calcd for C₂₈H₂₈BiF₆Sb: C, 41.56; H, 3.49. Found: C, 41.43; H, 3.32.

Example 3

Comparison (II) Between Effects of Cationic Photopolymerization Initiator Comprising Bismuthonium Salt and of Existing Cationic Photopolymerization Initiator on Cationic Photopolymerization Reaction Using Sensitizer

[0058] Cyclohexene oxide was placed as a monomer into a sample tube. Further, 10 mM of a tetrakis(4-methylphenyl)bismuthonium salt with SbF₆⁻ as an anion as a bismuthonium salt and 1 mM of perylene as a sensitizer were added thereto, and argon was passed therethrough for 5 minutes for substi-

tution. A solution of this photo-curable resin composition was irradiated with light ($h\nu > 436$ nm) for a predetermined period of time using a 250 W ultra high pressure mercury lamp (USHIO SX-UI250HP) as a light source through an aqueous copper sulfate solution filter (5.0 wt %, 5 cm) and a cut filter (product of HOYA: L42). The reaction mixture was poured into methanol. The precipitate was filtered off and washed with methanol, and then dried under vacuum. The molecular weight of the obtained polymer was determined using a GPC column calibrated with polyethylene oxide standards. The results are shown in Table 4. Table 4 also shows the results of an experiment conducted in the same manner using as an existing cationic photopolymerization initiator a tris(4-methylphenyl)sulfonium salt with SbF_6^- as an anion.

TABLE 4

Initiator	Time (min)	Yield/% ^a	$M_n (M_w/M_n)^b$
Bismuthonium salt	1.0	20	8000 (1.2)
	3.0	81	7900 (1.2)
	5.0	80	8000 (1.2)
Sulfonium salt	1.0	10	8300 (1.2)
	3.0	64	7600 (1.2)
	5.0	78	7900 (1.1)

^{a,b}the same as in Table 2

[0059] As is obvious from Table 4, it was revealed that as compared with an existing cationic photopolymerization initiator, a cationic photopolymerization initiator comprising a bismuthonium salt results in a higher photon yield in a cationic photopolymerization reaction using a sensitizer, and the reaction proceeds within a shorter period of time.

Example 4

Comparison (III) Between Effects of Cationic Photopolymerization Initiator Comprising Bismuthonium Salt and of Existing Cationic Photopolymerization Initiator on Cationic Photopolymerization Reaction Using Sensitizer

[0060] 2-(Phenoxy)methyl)oxirane was placed as a monomer into a sample tube. Further, 10 mM of a tetrakis(4-methylphenyl)bismuthonium salt with SbF_6^- as an anion as a bismuthonium salt and 1 mM of perylene as a sensitizer were added thereto, and argon was passed therethrough for 5 minutes for substitution. A solution of this photo-curable resin composition was irradiated with light ($h\nu > 360$ nm) for 1 minute using a 250 W ultra high pressure mercury lamp (USHIO SX-UI250HP) as a light source through an aqueous copper sulfate solution filter (5.0 wt %, 5 cm), and then allowed to stand in a dark room for 30 minutes. Subsequently, the reaction mixture was poured into methanol. The precipitate was filtered off and washed with methanol, and then dried under vacuum. The molecular weight of the obtained polymer was determined using a GPC column calibrated with polyethylene oxide standards. The results are shown in Table 5. Table 5 also shows the results of an experiment conducted in the same manner using as an existing cationic photopolymerization initiator a tris(4-methylphenyl)sulfonium salt with SbF_6^- as an anion.

TABLE 5

Initiator	Time (min)	Yield/% ^a	$M_n (M_w/M_n)^b$
Bismuthonium salt	1 + 30 (dark)	60	8000 (1.3)
Sulfonium salt	1 + 30 (dark)	64	8500 (1.2)

^{a,b}the same as in Table 2

[0061] As is obvious from Table 5, it was revealed that in this experiment system, a cationic photopolymerization initiator comprising a bismuthonium salt and an existing cationic photopolymerization initiator have similar effects.

Example 5

Comparison (IV) Between Effects of Cationic Photopolymerization Initiator comprising Bismuthonium Salt and of Existing Cationic Photopolymerization Initiator on Cationic Photopolymerization Reaction Using Sensitizer

[0062] (2-Chloroethoxy)ethylene was placed as a monomer into a sample tube. Further, 10 mM of a tetrakis(4-methylphenyl)bismuthonium salt with SbF_6^- as an anion as a bismuthonium salt and 1 mM of perylene as a sensitizer were added thereto, and argon was passed therethrough for 5 minutes for substitution. A solution of this photo-curable resin composition was irradiated with light ($h\nu > 360$ nm) for a predetermined period of time using a 250 W ultra high pressure mercury lamp (USHIO SX-UI250HP) as a light source through an aqueous copper sulfate solution filter (5.0 wt %, 5 cm). Subsequently, the reaction mixture was poured into methanol. The precipitate was filtered off and washed with methanol, and then dried under vacuum. The molecular weight of the obtained polymer was determined using a GPC column calibrated with polyethylene oxide standards. The results are shown in Table 6. Table 6 also shows the results of an experiment conducted in the same manner using as an existing cationic photopolymerization initiator a tris(4-methylphenyl)sulfonium salt with SbF_6^- as an anion.

TABLE 6

Initiator	Time (min)	Yield/% ^a	$M_n (M_w/M_n)^b$
Bismuthonium salt	0.5	34	13000 (1.4)
	1.0	68	12900 (1.4)
Sulfonium salt	0.5	20	14000 (1.5)
	1.0	60	12800 (1.4)

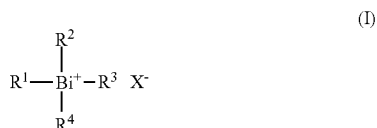
^{a,b}the same as in Table 2

[0063] As is obvious from Table 6, it was revealed that in a cationic photopolymerization reaction using a sensitizer, a cationic photopolymerization initiator comprising a bismuthonium salt is superior to an existing cationic photopolymerization initiator in terms of yield and degree of polymerization.

INDUSTRIAL APPLICABILITY

[0064] The present invention has an industrial applicability in the point that it can provide a novel cationic photopolymerization initiator that efficiently absorbs light and generates protons.

1. A cationic photopolymerization initiator characterized by comprising a bismuthonium salt represented by the following general formula (I):



wherein

- R¹ and R² may be the same or different and are each an optionally substituted monocyclic aryl group or an optionally substituted monocyclic heteroaryl group,
 R³ and R⁴ may be the same or different and are each an optionally substituted monocyclic aryl group; an optionally substituted monocyclic heteroaryl group; an optionally substituted fused polycyclic aromatic group; an optionally substituted fused polycyclic heterocyclic group; —CH=CR⁵R⁶, wherein R⁵ and R⁶ may be the same or different and are each a hydrogen atom, an optionally substituted alkyl group, an optionally substituted monocyclic aryl group, an optionally substituted monocyclic heteroaryl group, an optionally substituted fused polycyclic aromatic group, or an optionally substituted fused polycyclic heterocyclic group; or —(CH₂)_n—COR⁷, wherein R⁷ is an optionally substituted alkyl group, an optionally substituted monocyclic aryl group, an optionally substituted monocyclic heteroaryl group, an optionally substituted fused polycyclic aromatic group, or an optionally substituted fused polycyclic heterocyclic group, and n is 1 or 2, and
 X⁻ is an anion associated with a cation.
2. A cationic photopolymerization initiator according to claim 1, characterized in that R¹, R², and R³ are each an optionally substituted monocyclic aryl group.
3. A cationic photopolymerization initiator according to claim 1, characterized in that at least one of R³ and R⁴ is an optionally substituted fused polycyclic aromatic group.

4. A cationic photopolymerization initiator according to claim 1, characterized in that X⁻ is PF₆⁻, SbF₆⁻, AsF₆⁻, BF₄⁻, ORf⁻, NRf₂⁻, or B(Ar)₄⁻, wherein Rf is a perfluoroalkylsulfonyl group and Ar is an optionally substituted aryl group.

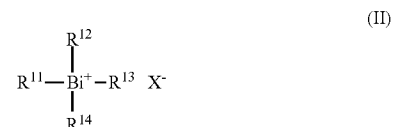
5. A method for polymerizing a cationic photopolymerizable compound characterized by using a cationic photopolymerization initiator according to claim 1.

6. A method according to claim 5, characterized in that the cationic photopolymerizable compound is a compound containing at least one member selected from an epoxy group, an oxetane group, and a vinyl ether group.

7. A photo-curable resin composition characterized by at least comprising a cationic photopolymerizable compound and a cationic photopolymerization initiator according to claim 1.

8. A cured product characterized by being obtainable by curing a photo-curable resin composition according to claim 7.

9. A bismuthonium salt characterized by being represented by the following general formula (II):



wherein

- R¹¹, R¹², and R¹³ may be the same or different and are each an optionally substituted monocyclic aryl group or an optionally substituted monocyclic heteroaryl group,
 R¹⁴ is an optionally substituted fused polycyclic aromatic group or an optionally substituted fused polycyclic heterocyclic group, and
 X⁻ is an anion associated with a cation.

* * * * *